

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	483	("205"/\$.ccls. "204"/\$.ccls.) and (apparatus system chamber device machine) and galvani\$3 and seal and (rod tub\$3 pip\$3 wire)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 15:00
L2	276	("205"/\$.ccls. "204"/\$.ccls.) and (apparatus system chamber device machine) and galvani\$3 and seal and (rod tub\$3 pip\$3 wire) and cathode	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 15:00
L3	249	("205"/\$.ccls. "204"/\$.ccls.) and (apparatus system chamber device machine) and galvani\$3 and seal and (rod tub\$3 pip\$3 wire) and cathode and contact	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 15:14
L4	2752	("205"/\$.ccls. "204"/\$.ccls.) and (apparatus system chamber device machine) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and seal and (rod tub\$3 pip\$3 wire) and cathode and contact	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 15:15
L5	2747	("205"/\$.ccls. "204"/\$.ccls.) and (apparatus system chamber device celle) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and seal and (rod tub\$3 pip\$3 wire) and cathode and contact	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 15:15
L6	2827	("205"/\$.ccls. "204"/\$.ccls.) and (apparatus system chamber device cell) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and seal and (rod tub\$3 pip\$3 wire) and cathode and contact	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 15:15
L7	1510	("205"/\$.ccls. "204"/\$.ccls.) and (apparatus system chamber device cell) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and seal and (rod tub\$3 pip\$3 wire) and cathode and contact and continuous	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 15:16

L8	97	("205"/\$.ccls. "204"/\$.ccls.) and (apparatus system chamber device cell) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and seal and (rod tub\$3 pip\$3 wire) and cathode near5 outside and contact and continuous	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 15:17
L9	12	("205"/129,133,137-141.ccls. "204"/198206,224R,272,275.1.ccls.) and (apparatus system chamber device cell) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and seal and (rod tub\$3 pip\$3 wire) and cathode near5 outside and contact and continuous	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 15:19
L10	240	("205"/129,133,137-141.ccls. "204"/198206,224R,272,275.1.ccls.) and (apparatus system chamber device cell) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and seal and (rod tub\$3 pip\$3 wire) and cathode and contact and continuous	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 15:20
L11	183	("205"/129,133,137-141.ccls. "204"/198206,224R,272,275.1.ccls.) and (apparatus system chamber device cell) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and seal and (rod tub\$3 pip\$3 wire) and cathode same contact and continuous	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 15:20
L12	94	("205"/129,133,137-141.ccls. "204"/198206,224R,272,275.1.ccls.) and (apparatus system chamber device cell) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and seal and (rod tub\$3 pip\$3 wire) and cathode same (electrical near5 contact) and continuous	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 15:21
L13	35	("205"/129,133,137-141.ccls. "204"/198206,224R,272,275.1.ccls.) and (apparatus system chamber device cell) near10 seal and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and (rod tub\$3 pip\$3 wire) and cathode same (electrical near5 contact) and continuous	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 15:24

L14	2998	("205"/129,133,137-141.ccls. "204"/198206,224R,272,275.1.ccls.) and (apparatus system chamber device cell) (remov\$3 with electrolyte) near10 seal and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and (rod tub\$3 pip\$3 wire) and cathode same (electrical near5 contact) and continuous	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 15:25
L15	0	("205"/129,133,137-141.ccls. "204"/198206,224R,272,275.1.ccls.) and (apparatus system chamber device cell) and ((remov\$3 with electrolyte) near10 seal) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and (rod tub\$3 pip\$3 wire) and cathode same (electrical near5 contact) and continuous	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 15:25
L16	0	("205"/129,133,137-141.ccls. "204"/198206,224R,272,275.1.ccls.) and (apparatus system chamber device cell) and ((remov\$3 with electrolyte) near10 seal) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and (rod tub\$3 pip\$3 wire) and cathode and (electrical\$3 near5 contact) and continuous	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 15:26
L17	0	("205"/129,133,137-141.ccls. "204"/198206,224R,272,275.1.ccls.) and (apparatus system chamber device cell) and ((remov\$3 with electrolyte) near10 seal) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and (rod tub\$3 pip\$3 wire) and cathode and (electrical\$3 near5 contact) and continuous	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 15:26
L18	16	("205"/129,133,137-141.ccls. "204"/198206,224R,272,275.1.ccls.) and (apparatus system chamber device cell) and ((remov\$3 with electrolyte) same seal) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and (rod tub\$3 pip\$3 wire) and cathode and (electrical\$3 near5 contact) and continuous	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 15:32

L19	23	("205"/129,133,137-141.ccls. "204"/198206,224R,272,275.1.ccls.) and (apparatus system chamber device cell) and ((remov\$3 with electrolyte) same seal\$3) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and (rod tub\$3 pip\$3 wire) and cathode and (electrical\$3 near5 contact) and continuous	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 16:41
L20	4334	("205"/129,133,137-141.ccls. "204"/198206,224R,272,275.1.ccls.) (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and (rod tub\$3 pip\$3 wire) and cathode and galvani\$4 and automobile	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 16:42
L21	4140	("205"/129,133,137-141.ccls. "204"/198206,224R,272,275.1.ccls.) (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and (rod tub\$3 pip\$3 wire) and cathode and galvani\$4 and automobile and zinc and brake	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 16:43
L22	0	("205"/129,133,137-141.ccls. "204"/198206,224R,272,275.1.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and (rod tub\$3 pip\$3 wire) and cathode and galvani\$4 and automobile and zinc and brake	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 16:43
L23	0	("205"/129,133,137-141.ccls. "204"/198206,224R,272,275.1.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and (rod tub\$3 line pip\$3 wire) and cathode and galvani\$4 and automobile and zinc and brake	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 16:43
L24	13	("205"/129,133,137-141.ccls. "204"/198206,224R,272,275.1.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and (rod tub\$3 line pip\$3 wire) and cathode and galvani\$4 and automobile and zinc	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 16:44
L25	116	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and (rod tub\$3 line pip\$3 wire) and cathode and galvani\$4 and automobile and zinc	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 16:45

L26	5	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and (rod tub\$3 line pip\$3 wire) and cathode and galvani\$4 and automobile and zinc and brake	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 16:45
S1	781	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and (apparatus system chamber device machine) and galvaniz\$3	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/31 10:20
S2	0	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and (apparatus system chamber device machine) and galvaniz\$3 and jet adj cell	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/31 10:21
S3	444	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and (apparatus system chamber device machine) and galvaniz\$3 and (chamber zone cell)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/31 10:24
S4	325	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and (apparatus system chamber device machine) and galvaniz\$3 and (chamber zone cell) and zinc	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/31 10:25
S5	17	("205"/\$.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and (apparatus system chamber device machine) and galvaniz\$3 and (chamber zone cell) and zinc and baffle	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/31 10:36
S6	12	("205"/76-77,133,137-141.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and (apparatus system chamber device machine) and galvaniz\$3 and (chamber zone cell) and zinc and baffle	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/31 10:51

S7	0	("205"/76-77,133,137-141.ccls. "204"/\$.ccls.) and (electrolysis electrolytic electrochemic\$4 electrodeposit\$5 electroplat\$5) and (apparatus system chamber device machine) and galvaniz\$3 and (chamber zone cell) and zinc and brake adj line	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/31 10:52
S8	1	("205"/76-77,133,137-141.ccls. "204"/\$.ccls.) and (apparatus system chamber device machine) and galvaniz\$3 and (chamber zone cell) and zinc and brake adj line	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/31 10:53
S9	115	("205"/76-77,133,137-141.ccls. "204"/\$.ccls.) and (apparatus system chamber device machine) and galvaniz\$3 and (chamber zone cell) and zinc and (rod wire)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/31 16:14
S10	115	("205"/76-77,133,137-141.ccls. "204"/\$.ccls.) and (apparatus system chamber device machine) and galvaniz\$3 and (chamber zone cell) and zinc and (rod wire)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/31 16:14
S11	50	("205"/\$.ccls. "204"/\$.ccls.) and (apparatus system chamber device machine) and galvaniz\$3 and (chamber zone cell) and zinc and (rod wire) not S10	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/01 14:58
S12	80	(apparatus system chamber device machine) and galvaniz\$3 and (chamber zone cell) and zinc and (rod wire) and baffle	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/31 16:30
S13	40	(apparatus system chamber device machine) and galvaniz\$3 and (chamber zone cell) and zinc and (rod wire) and baffle and seal	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/31 17:21
S14	4	("3707400").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/08/31 17:21

S15	9	(apparatus system chamber device machine) and galvaniz\$3 and (chamber zone cell) and zinc and (rod tube pipe wire) and baffle and seal and wiping	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/08/31 17:24
-----	---	--	---	----	----	------------------